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4

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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/652,350	08/29/2003	John P. Barnak	42390P15042	42390P15042 1298	
8791	7590 06/29/2005	EXAMINER			
BLAKELY SOKOLOFF TAYLOR & ZAFMAN 12400 WILSHIRE BOULEVARD SEVENTH FLOOR LOS ANGELES, CA 90025-1030			NGUYEN	NGUYEN, DAO H	
			ART UNIT	PAPER NUMBER	
			2818		
			DATE MAILED: 06/29/2005		

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application	n No.	Applicant(s)			
Office Action Summary		10/652,35	0	BARNAK ET AL.			
		Examiner		Art Unit			
		Dao H. Ng		2818			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status							
1)🛛	1)⊠ Responsive to communication(s) filed on <u>03 June 2005</u> .						
·	This action is FINAL . 2b)⊠ This action is non-final.						
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims							
5)□ 6)⊠ 7)□	Claim(s) 1-6 and 13-19 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. Claim(s) is/are allowed. Claim(s) 1-6 and 13-19 is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction and/or election requirement.						
Applicati	on Papers						
 9) The specification is objected to by the Examiner. 10) The drawing(s) filed on 29 August 2003 is/are: a) accepted or b) objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. 							
Priority under 35 U.S.C. § 119							
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.							
Attachment(s)							
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)							
2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 0204 & 0205.							

Application/Control Number: 10/652,350

Art Unit: 2818

DETAILED ACTION

Page 2

In response to the communications dated 08/29/2003 through 06/03/2005, claims
 and 13-19 are active in this application.

Claim(s) 7-12, and 20-25 have been cancelled.

Acknowledges

2. Receipt is acknowledged of the following items from the Applicant.

Information Disclosure Statement (IDS) filed on 02/12/2004 and 02/14/2005. The references cited on the PTOL 1449 form have been considered.

Applicant is requested to cite any relevant prior art if being aware on form PTO-1449 in accordance with the guidelines set for in M.P.E.P. 609.

3. Applicant made a provisional election without traverse to prosecute the invention of Group I, claims 1-6 and 13-19, drawn to semiconductor devices. Affirmation of this election was made in the Response to Restriction Requirement, filed 06/03/2005.

Claims 7-12 and 20-25 have been cancelled without traverse.

Applicant has the right to file a divisional application covering the subject matter of the non-elected claims.

Application/Control Number: 10/652,350

Art Unit: 2818

Claim Rejections - 35 USC § 102

Page 3

4. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless --

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

5. Claim(s) 1 and 13 is/are rejected under 35 U. S. C. § 102 (e) as being anticipated by U.S. Patent No. 6,713,358 to Chau et al.

Regarding claim 1, Chau discloses a semiconductor device, as shown in figs. 1, comprising:

a dielectric layer 130;

a silicon-nitride layer 140 superjacent to the dielectric layer 130;

a polysilicon gate layer 160 superjacent to the silicon-nitride layer 140. See also col. 3, lines 4-66.

Regarding claim 13, Chau discloses an apparatus comprising:

a gate structure including a silicon-nitride layer 140;

a substrate 110 coupled to the gate structure;

Art Unit: 2818

a drain and a source coupled to the substrate (this is inherent since the device is a MOS Field-Effect Transistor which has the described gate structure). See col. 1, lines 13-27, and col. 3, lines 4-66.

6. Claim(s) 1-6 and 13-19 are rejected under 35 U. S. C. § 102 (e) as being anticipated by U.S. Patent No. 6,894,353 to Samavedam et al.

Regarding claim 1, Samavedam discloses a semiconductor device, as shown in figs. 6-7, comprising:

- a dielectric layer 108;
- a silicon-nitride layer 114 superjacent to the dielectric layer 108;
- a polysilicon gate layer 116 superjacent to the silicon-nitride layer 114. See col. 4, lines 5-58.

Regarding claim 13, Samavedam discloses an apparatus, as shown in figs. 6-7, comprising:

- a gate structure including a silicon-nitride layer 114;
- a substrate 102 coupled to the gate structure;
- a source/drain 130/142 coupled to the substrate. See col. 4, lines 5-58, and col. 7, line 33 to col. 8, line 24.

Application/Control Number: 10/652,350

Art Unit: 2818

Regarding claims 2 and 14, Samavedam discloses the semiconductor device wherein the silicon-nitride layer 114 has been deposited upon the dielectric layer 108 using a physical vapor deposition (PVD) process. See col. 4, lines 24-58.

Regarding claims 3 and 15, Samavedam discloses the semiconductor device wherein the dielectric layer 108 has a dielectric constant of twenty or greater. See col. 4, lines 5-23; col. 7, lines 22-32. See also US Patent No. 6,713,358 to Chau et al., col. 2, lines 4-25.

Regarding claims 4-5 and 17-18, Samavedam discloses the semiconductor device wherein the polysilicon gate layer is either an n-type or a p-type. This is inherent.

Regarding claims 6 and 19, Samavedam discloses the semiconductor device wherein the semiconductor device is a complementary metal-oxide-semiconductor device. See col. 3, line 36 to col. 5, line 38; col. 6, line 24 to col. 8, line 46.

Regarding claim 16, Samavedam discloses the apparatus wherein the gate structure further includes a polysilicon layer 116 coupled to the silicon-nitride layer 114. See figs. 6-7.

Art Unit: 2818

Conclusion

- 7. A shortened statutory period for response to this action is set to expire 3 (three) months and 0 (zero) day from the day of this letter. Failure to respond within the period for response will cause the application to become abandoned (see M.P.E.P 710.02(b)).
- 8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dao H. Nguyen whose telephone number is (571)272-1791. The examiner can normally be reached on Monday-Friday, 9:00 AM 6:00 PM. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571)272-1787. The fax numbers for all communication(s) is 703-872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (571)272-1625.

Supervisory Patent Examiner Technology Center 2800

Dao H. Nguyen Art Unit 2818 June 24, 2005

